



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Tomohisa KONNO et al

SERIAL NO.: 10/626,521

GROUP ART UNIT: 3723

FILED: July 25, 2003

EXAMINER: RACHUBA, MAURINA T.

FOR: AQUEOUS DISPERSION FOR CHEMICAL MECHANICAL POLISHING
AND PRODUCTION PROCESS OF SEMICONDUCTOR DEVICE

REQUEST FOR EXTENSION OF TIME
UNDER 37 C.F.R. §1.136

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

It is hereby requested that a three month extension of time be granted to May 13, 2007 for:

- filing a response to the Official Action dated: November 13, 2006.
- responding to the requirements in the Notice of Allowability dated:
- filing the Formal Drawings. The Issue Fee due has been timely filed.
- responding to the Notice to File Missing Parts of Application dated:
- filing a Notice of Appeal. A timely response to the final rejection, due has been filed.
- filing an Appeal Brief. A Notice of Appeal was filed on:
- Applicant claims small entity status. See 37 CFR 1.27. Therefore, the fee amount shown below is reduced by one-half.

The required fee of \$1,020.00 is enclosed herewith by credit card payment and any further charges may be made against the Attorney of Record's Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

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